

169741U.S. PTO
10/06/02
02/20/02

Best Available Copy

U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
100818	02/20/02	38	593	2818	T1HO

APPL. INVENTOR: Bridge Jerome; Ahn Kie; Forbes Leonard;

CONTINUING DATA VERIFIED:

Yes, Hf

THIS APPLICATION IS A CIP OF 09/943,134 08/30/2001

PREVIOUS APPLICATIONS VERIFIED:

(None)

<input type="checkbox"/> PUBLISHED	<input type="checkbox"/> RESCIND
Foreign priority claim: <input type="checkbox"/> yes <input checked="" type="checkbox"/> no	ATTORNEY DOCKET NO
35 USC 110 conditions met: <input type="checkbox"/> yes <input checked="" type="checkbox"/> no	1303.045US1
Verified and Acknowledged Examiner's Initials: Hf	

TITLE: Atomic layer deposition of metal oxide and/or low asymmetrical tunnel barrier interplay insulators

DRAWINGS			CLAIMS ALLOWED	
Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
			NOTICE OF ALLOWANCE MAILED	
			ISSUE FEE	
			Amount Due	Date Paid
			ISSUE BATCH NUMBER	

NOTICE OF ALLOWANCE MAILED

ISSUE FEE

Amount Due	Date Paid

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DISCLAIMER

FORMAL DRAWING

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